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(12) **United States Design Patent** (10) **Patent No.:** **US D934,820 S**  
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(54) **SEMICONDUCTOR DEVICE**

(56) **References Cited**

(71) Applicant: **Panasonic Intellectual Property Management Co., Ltd.**, Osaka (JP)

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(72) Inventors: **Ryosuke Okawa**, Nara-ken (JP);  
**Toshikazu Imai**, Hyogo-ken (JP);  
**Kazuma Yoshida**, Kyoto-fu (JP);  
**Tsubasa Inoue**, Osaka-fu (JP); **Takeshi Imamura**, Kyoto-fu (JP)

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(73) Assignee: **NUVOTON TECHNOLOGY CORPORATION JAPAN**,  
Nagaokakyo (JP)

(\*\*) Term: **15 Years**

(Continued)

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USPC ..... **D13/182**

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*Primary Examiner* — Elizabeth J Oswecki

(74) *Attorney, Agent, or Firm* — Crowell & Moring LLP

(57) **CLAIM**

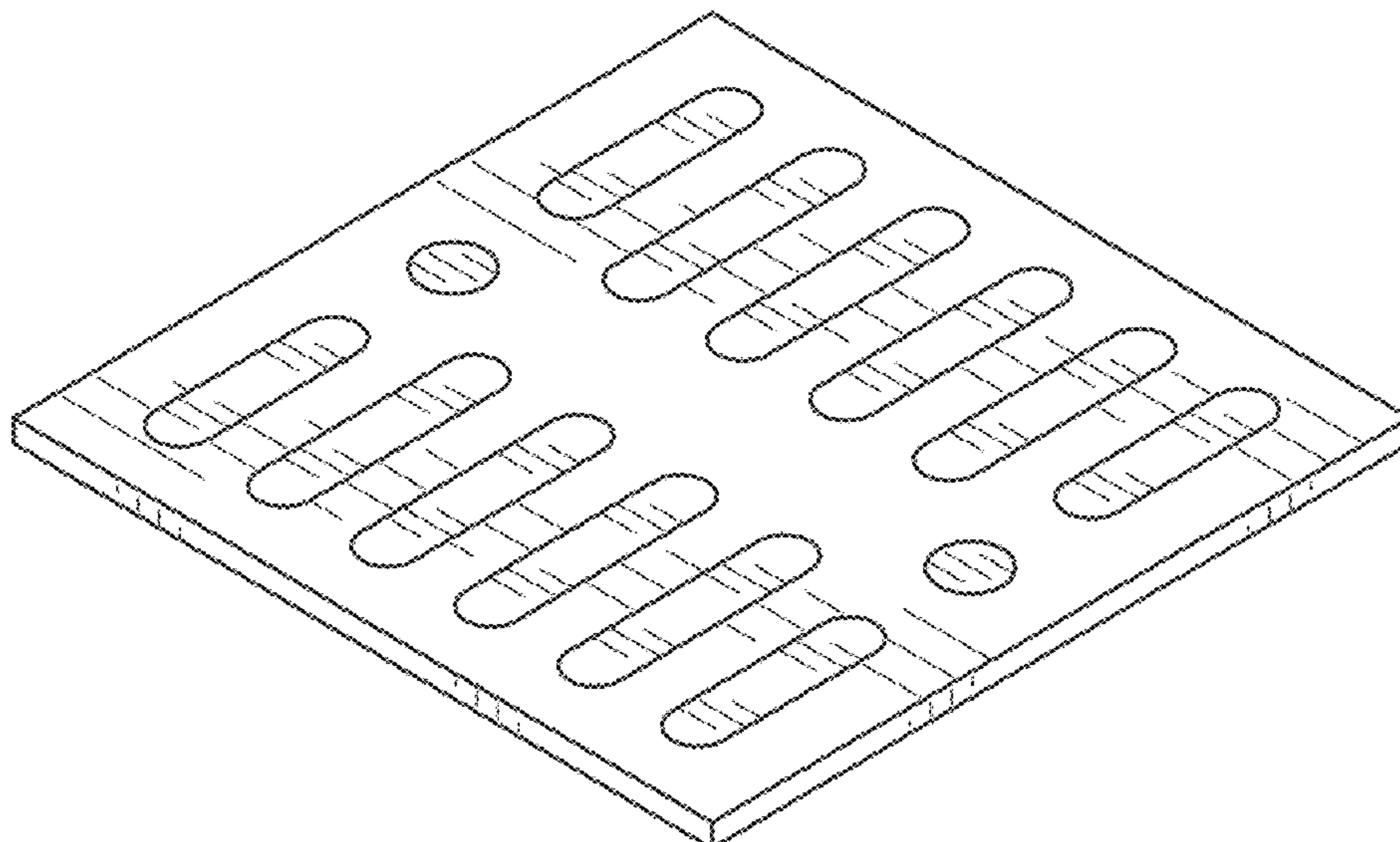
The ornamental design for a semiconductor device, as shown and described.

**DESCRIPTION**

FIG. 1 is a perspective view of a semiconductor device showing our new design;  
FIG. 2 is a front view thereof;  
FIG. 3 is a rear view thereof;  
FIG. 4 is a left side view thereof;  
FIG. 5 is a right side view thereof;  
FIG. 6 is a top view thereof; and,  
FIG. 7 is a bottom view thereof.

See application file for complete search history.

**1 Claim, 4 Drawing Sheets**



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FIG. 1

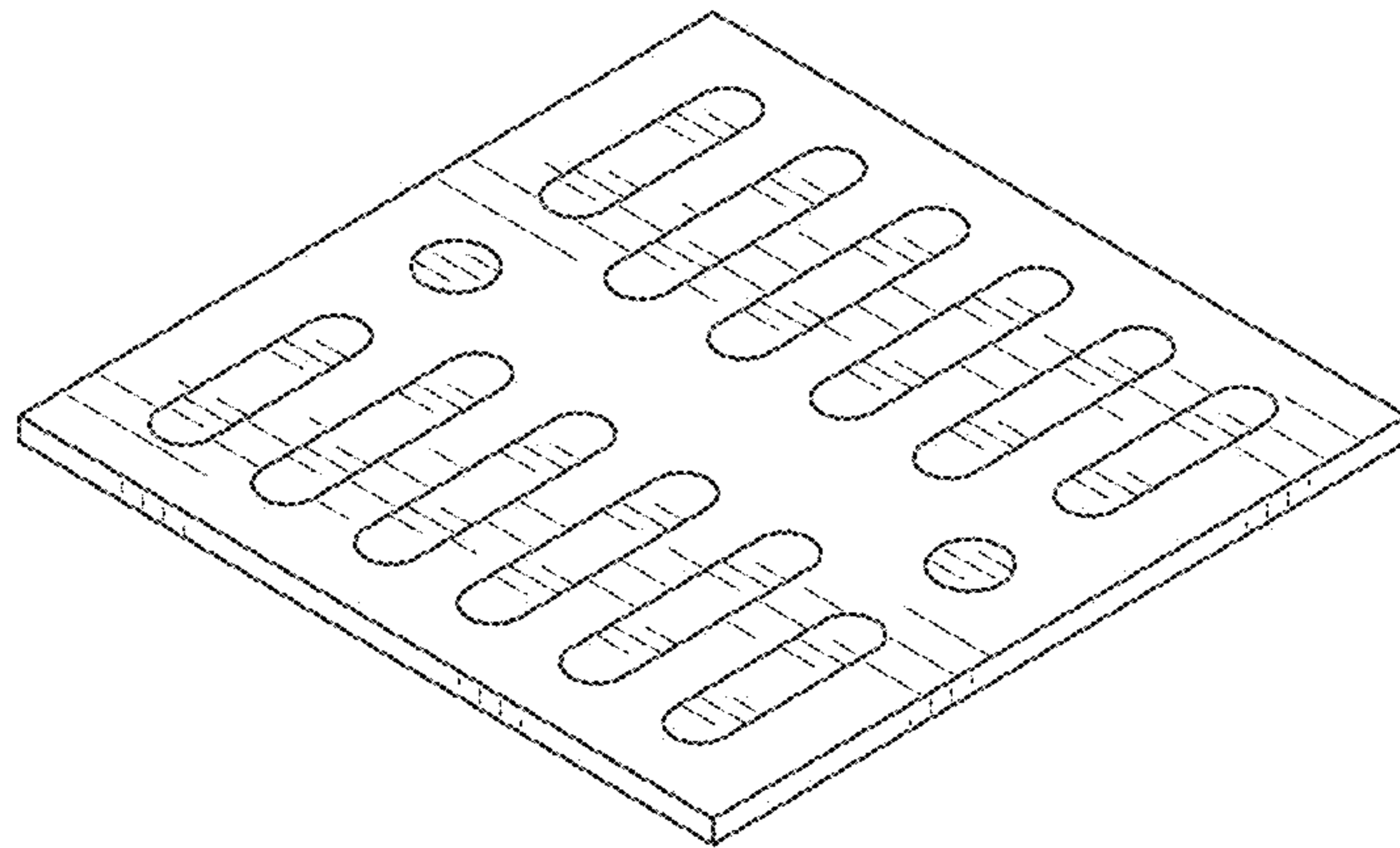


FIG. 2

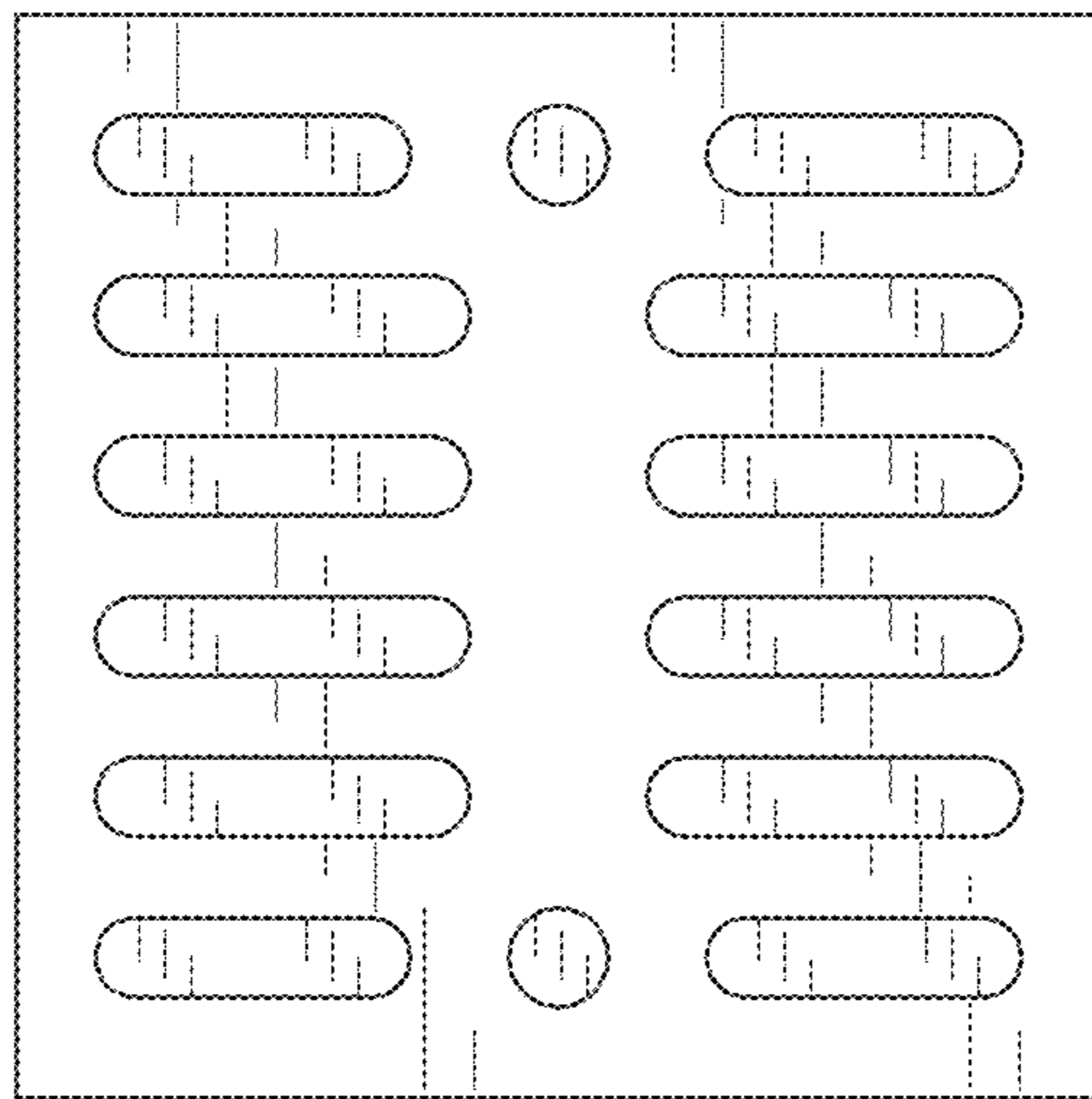


FIG. 3

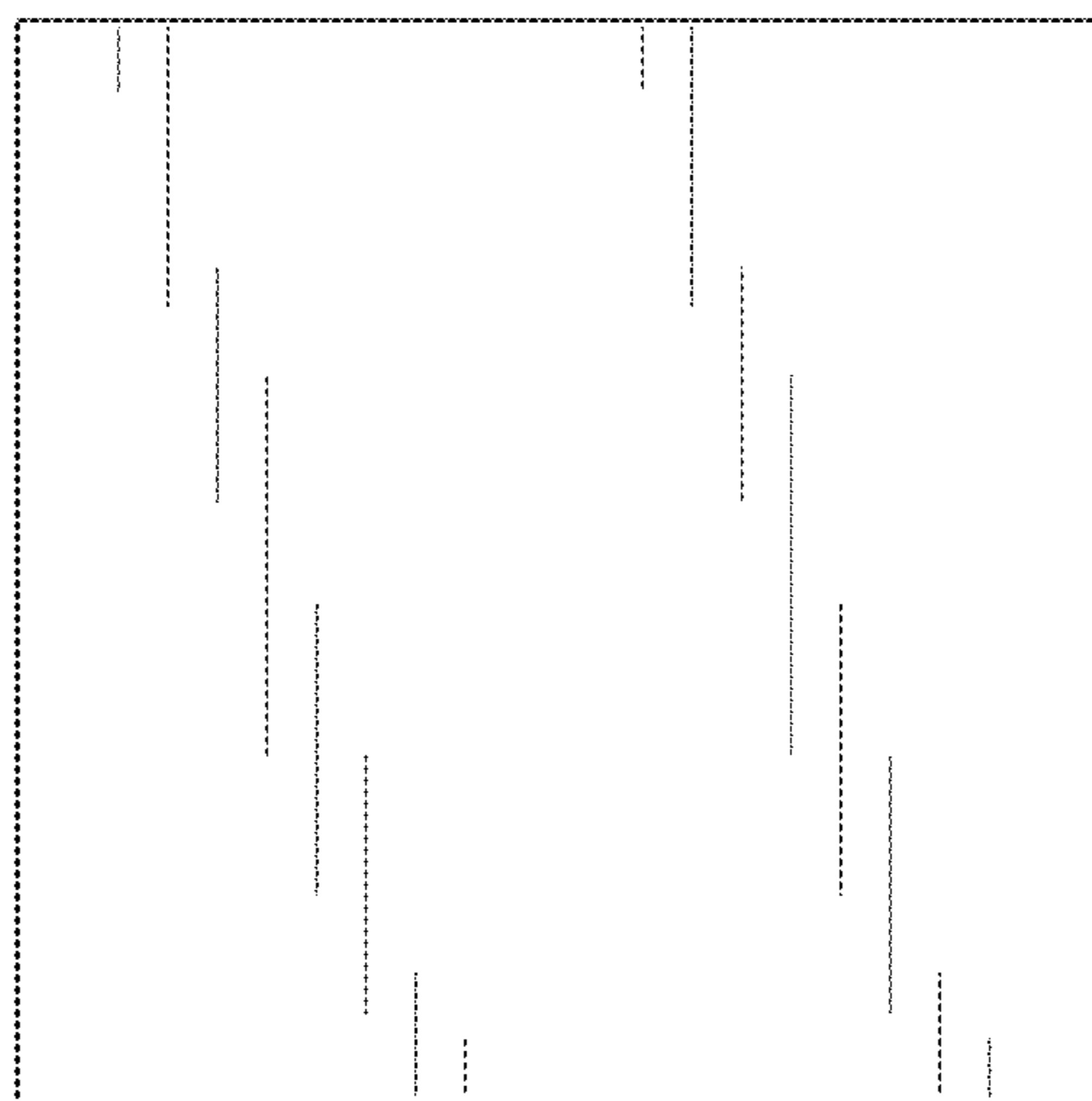


FIG. 4



FIG. 5



FIG. 6

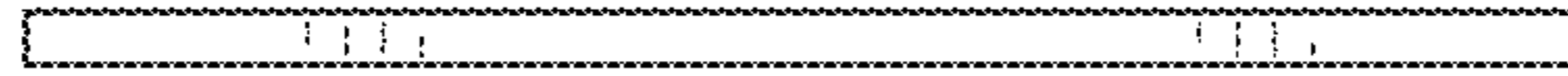


FIG. 7

